

Trasduttori resistivi di temperatura

- Positive thermal coefficient (PTC)
- Negative thermal coefficient (NTC)

anche RTD (Resistive Temperature Detectors), o termistori

PTC (Callendar, van Dusen):

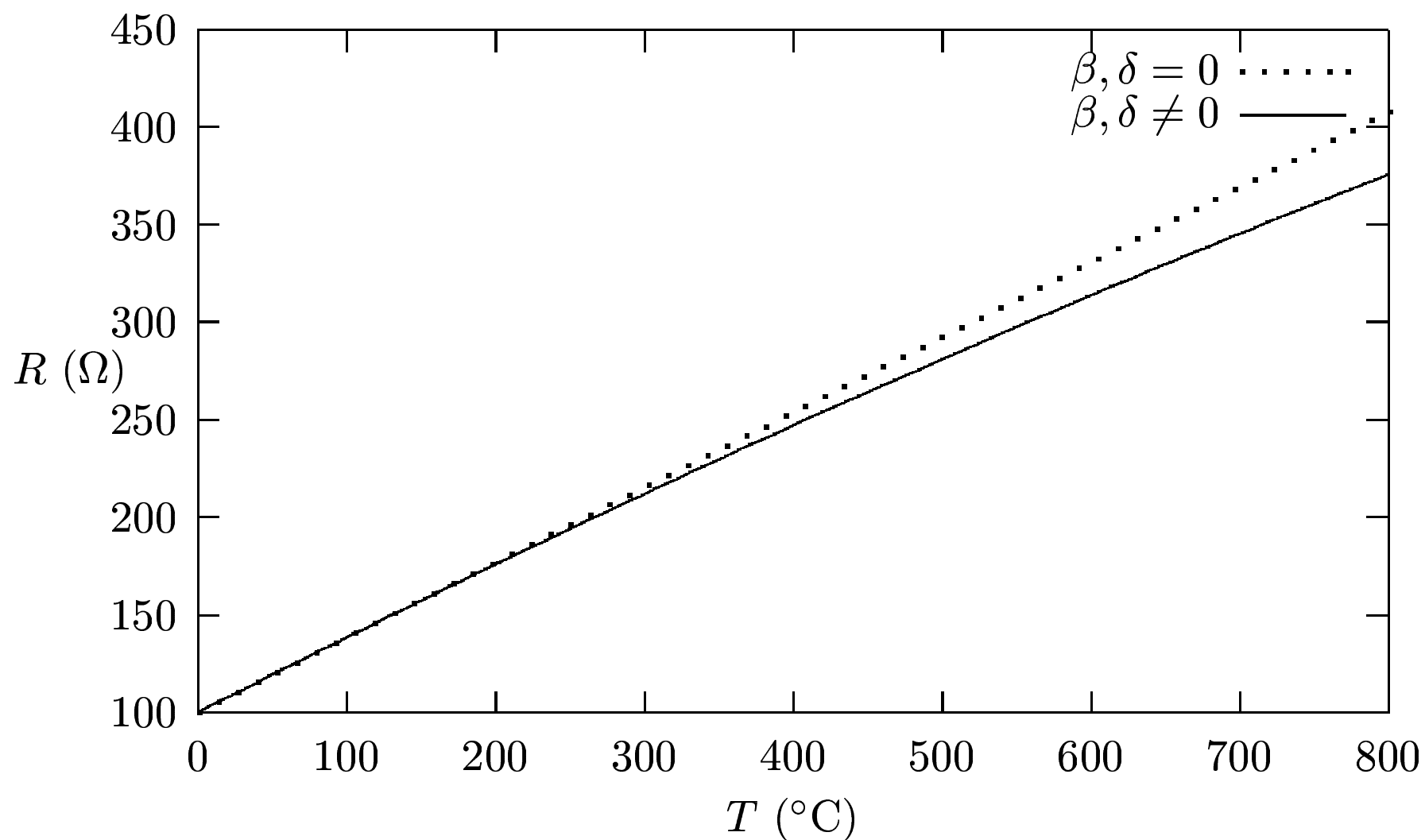
$$R(T) = R_0 \left\{ 1 + \alpha \left[T + \delta \left(1 - \frac{T}{100} \right) \frac{T}{100} + \beta \left(1 - \frac{T}{100} \right) \left(\frac{T}{100} \right)^3 \right] \right\}$$

$$R_0 = R(0^\circ \text{C})$$

Pt:

$$R_0 = 100 \Omega, \quad \alpha = 0.00385^\circ \text{C}^{-1}(\text{Pt}) \quad \delta = 1.499$$

$$\begin{array}{lll} \beta : \text{costante di Van Dusen :} & \beta = 0 & T < 0^\circ \text{C} \\ & \beta = 0.10863 & T > 0^\circ \text{C} \end{array}$$

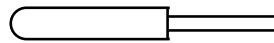


$$R(T) = R_0 \left\{ 1 + \alpha \left[T + \delta \left(1 - \frac{T}{100} \right) \frac{T}{100} + \beta \left(1 - \frac{T}{100} \right) \left(\frac{T}{100} \right)^3 \right] \right\}$$

Pt100

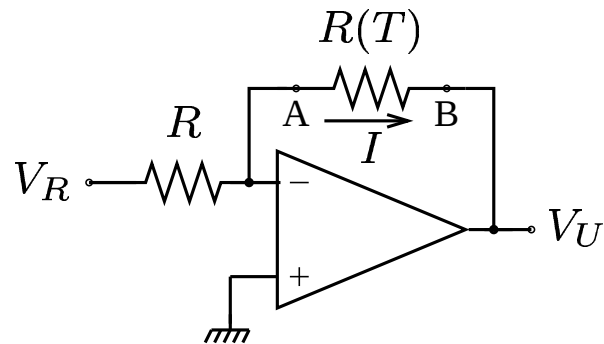
$$R(T) = R_0[1 + \alpha(T - T_0)], \quad T < 500^\circ\text{C}$$

Pt100

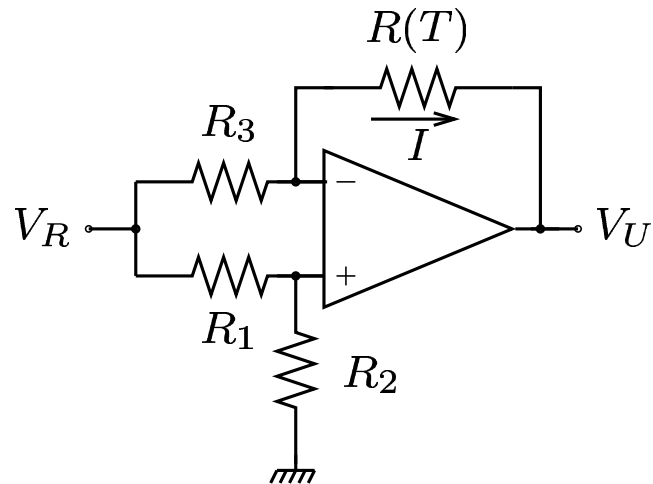


- range: $-20^\circ\text{C} \div 500^\circ\text{C}$, $-50^\circ\text{C} \div 500^\circ\text{C}$
- $\alpha = 0.00385 \, \Omega/\Omega/^\circ\text{C}$ ($0.0039 \, \Omega/\Omega/^\circ\text{C}$)
- stabilità: drift $< 0.1^\circ\text{C}/\text{anno}$
- dimensioni: 1x10 mm circa
- componenti standard, strumentazione “dedicata”

Pt100



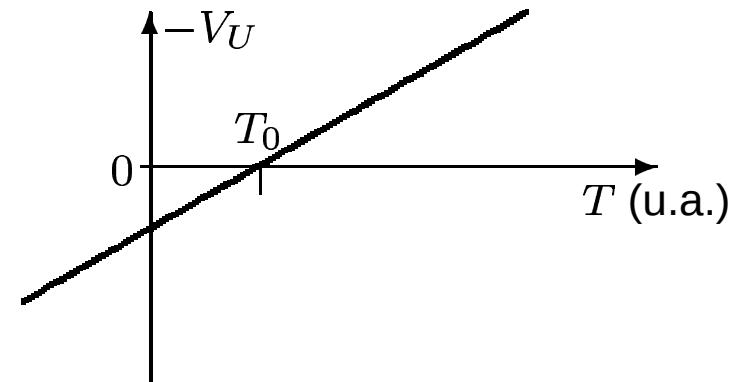
$$I = \frac{V_R}{R}, \quad (V_{AB} \text{ misurata con A.S.})$$



$$V_U(T_0) = 0 \text{ (bil.)}$$

$$I = V_R \frac{R_1}{R_3(R_1 + R_2)}$$

$$\frac{dV_U}{dT} = -\alpha I R_0$$

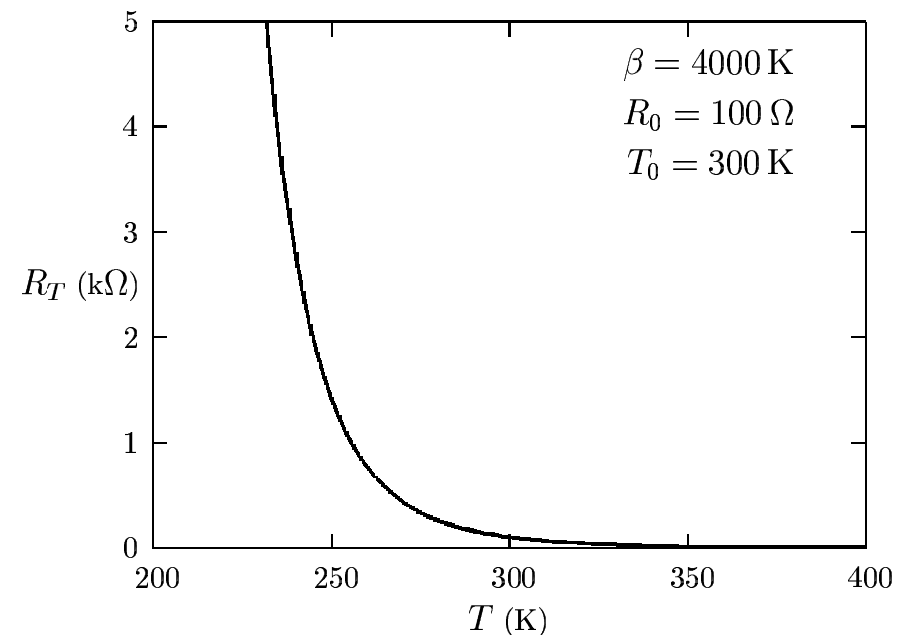


NTC

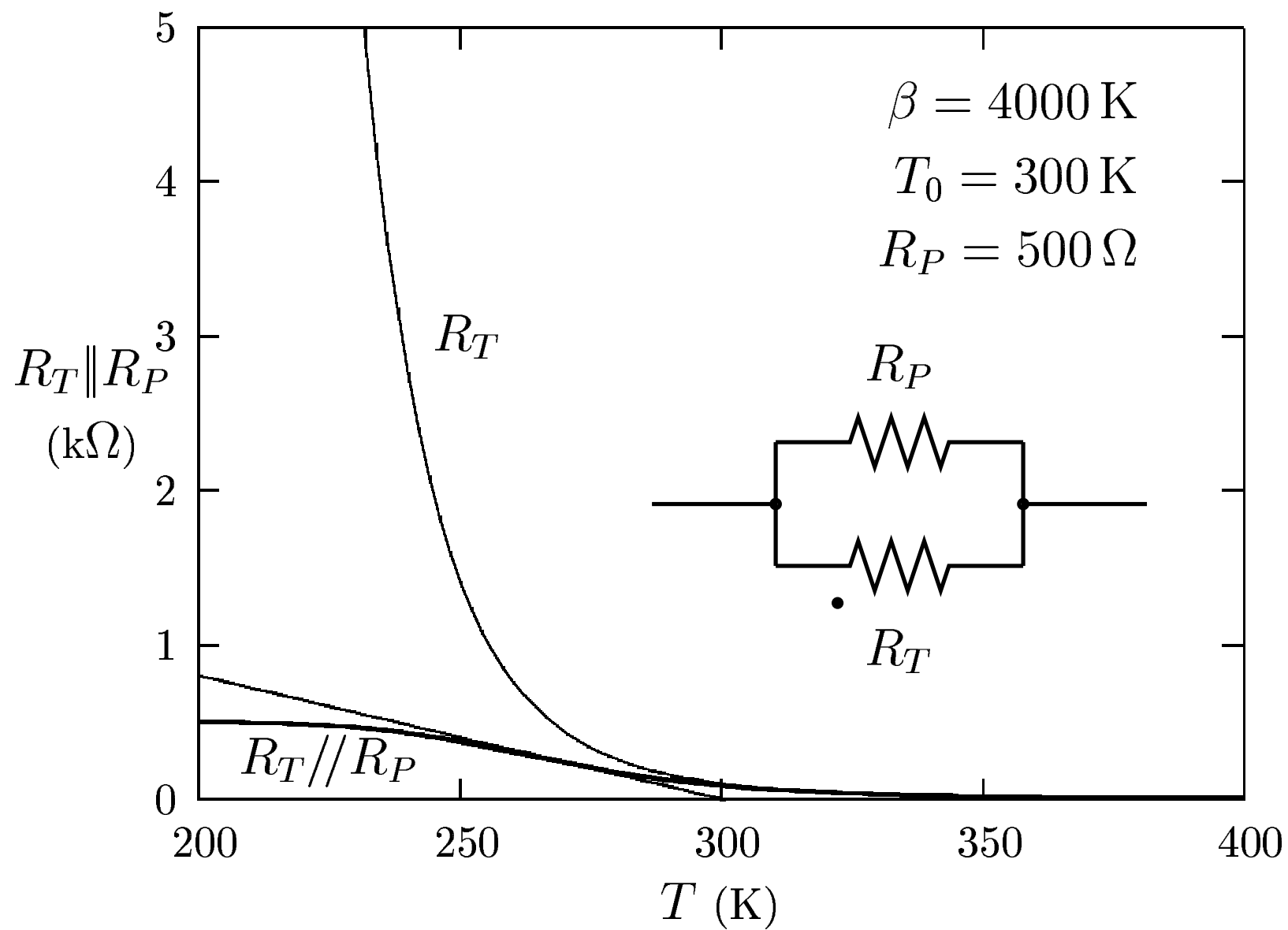
- realizzati con ossidi di Mn, Ni, Co, Cu, Fe, Ti, o con semiconduttori
- fortemente non lineari
- applicazioni in ambito biomedico (flusso respiratorio, temperature, calore di reazione, ...), facilmente miniaturizzabili.

$$\ln(R) = a_0 + \frac{a_1}{T} \left(+ \frac{a_2}{T^2} + \frac{a_3}{T^3} \right)$$

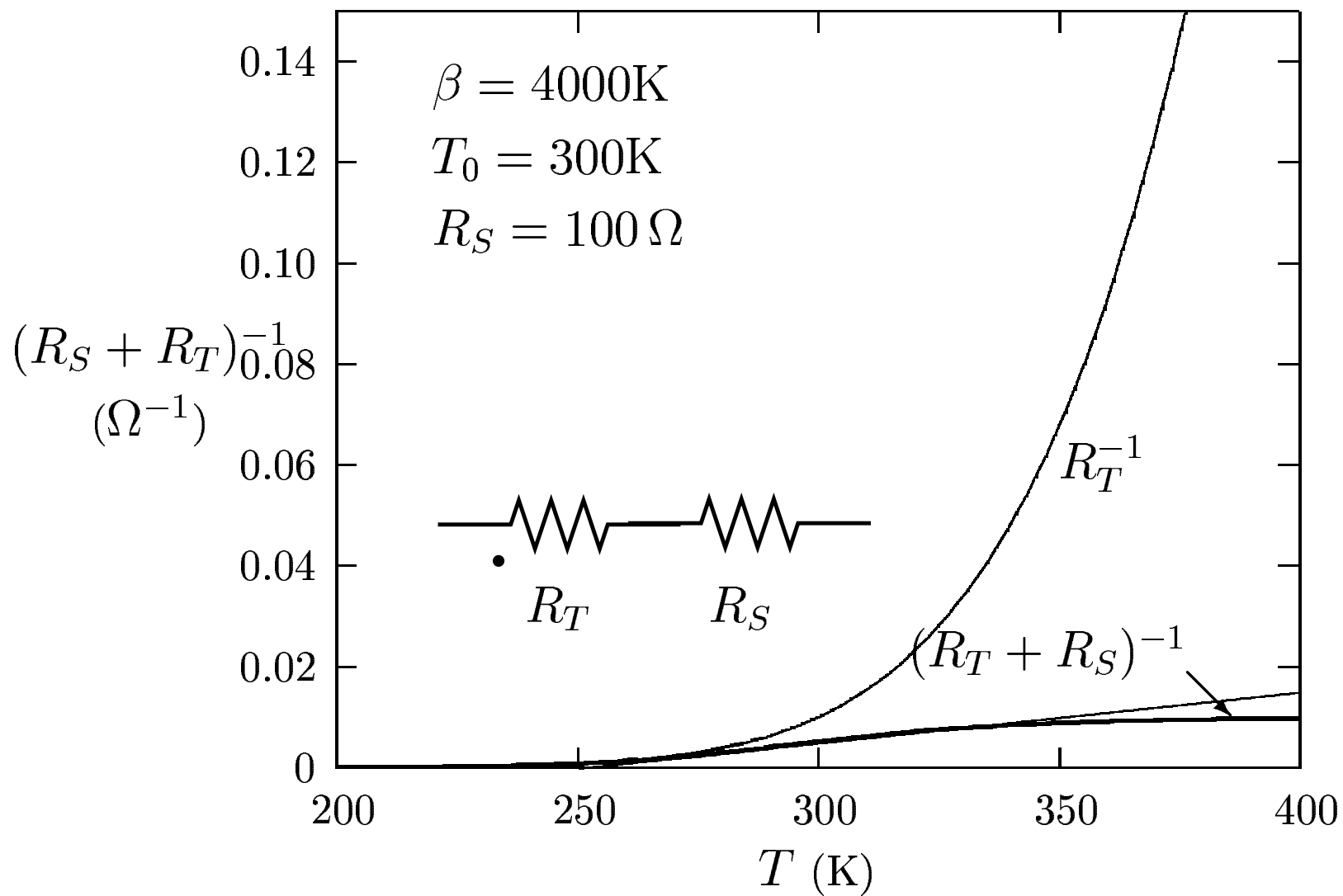
$$R(T) = R_0 \exp \left[\beta \left(\frac{1}{T} - \frac{1}{T_0} \right) \right]$$



NTC - linearizzazione



NTC - linearizzazione



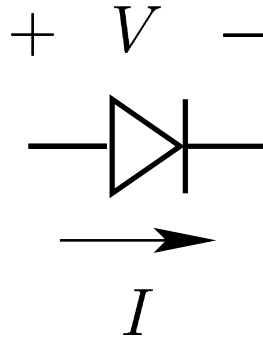
Sensori integrati di temperatura

Dispositivi a semiconduttore:

- (Possibilità di) integrazione con l'elettronica di pilotaggio/elaborazione:
 - riduzione delle dimensioni complessive;
 - riduzione dei parametri parassiti (C);
 - maggiore affidabilità;
- Sensori basati su (costituiti da) circuiti integrati.
 - eventualmente a loro volta integrabili con l'elettronica di pilotaggio/elaborazione.

Sensori di temperatura a semiconduttore

1 - giunzione p-n

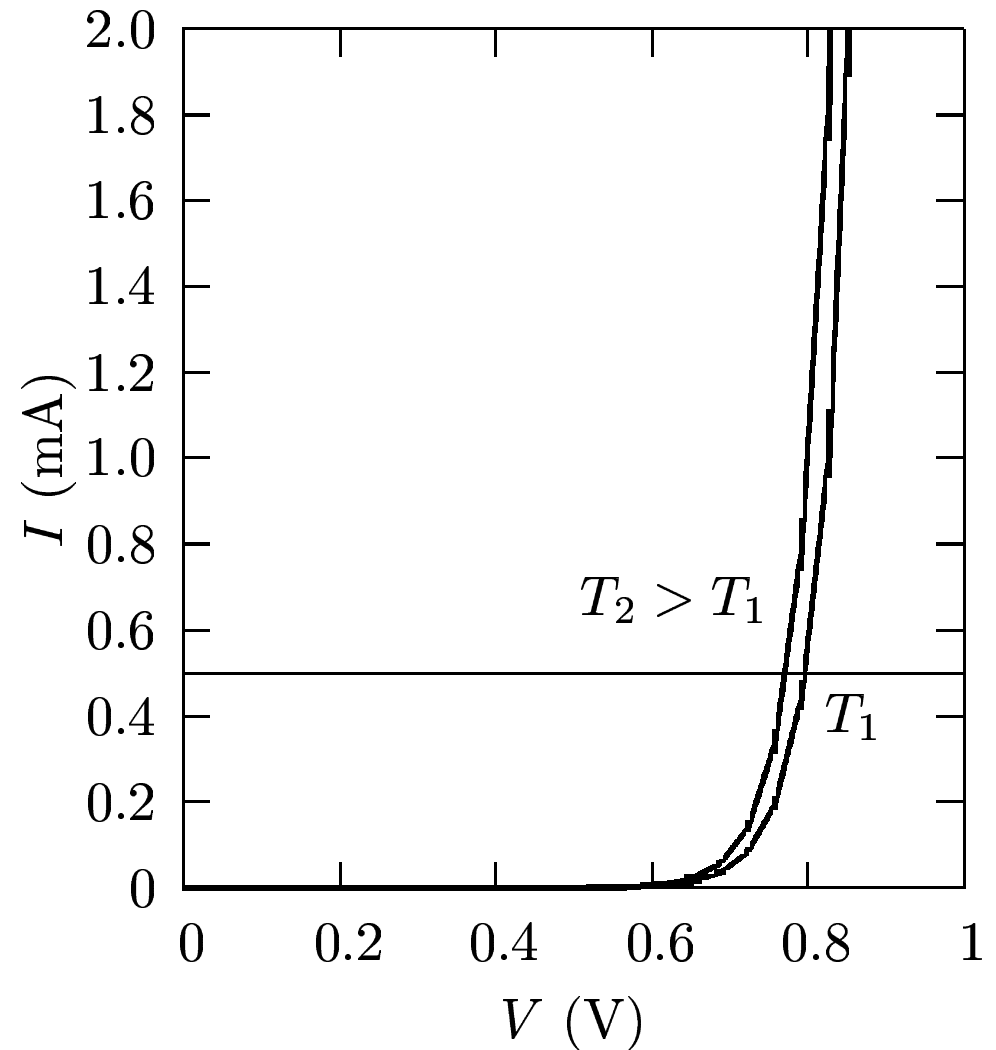


legge della giunzione:

$$I(V) = I_0[\exp(V/\eta V_T) - 1]$$

dipendenza da T :

$$\frac{dV}{dT} \simeq -2.5 \text{ mV} \quad (\text{Si, } I \text{ costante})$$



Curva di calibrazione

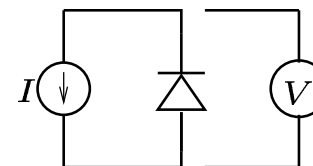
Silicon Diode Thermometer Sensor Model: Si430

Calibration Current: 10 microamps

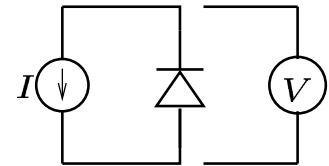
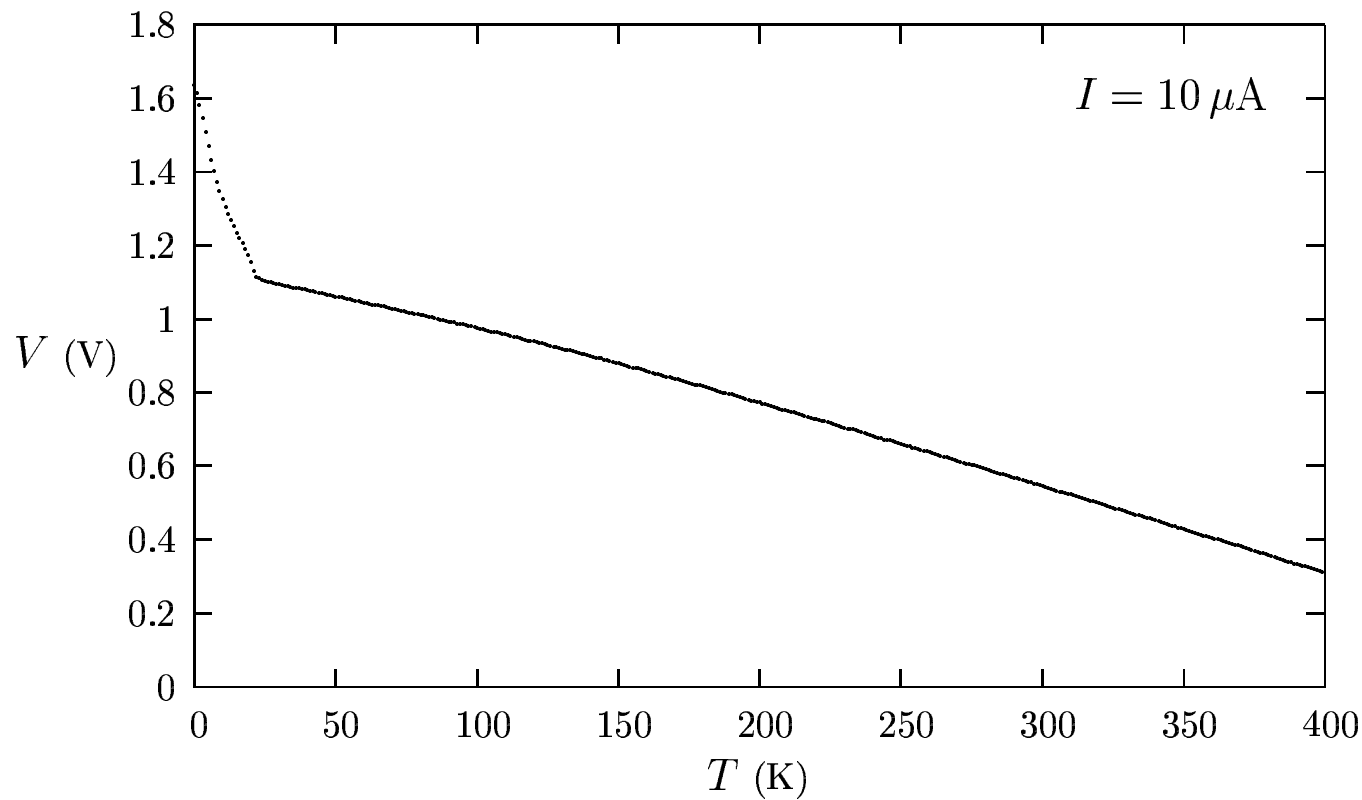
Typical Response 020-122

Temp. K	+0.0	+1.0	+2.0	+3.0	+4.0	+5.0	+6.0	+7.0	+8.0	+9.0
0		1.64342	1.62255	1.59108	1.55483	1.51590	1.47740	1.44098	1.40827	1.37998
10	1.35568	1.33317	1.31277	1.29401	1.27621	1.25932	1.24342	1.22816	1.21325	1.19816
20	1.18193	1.16246	1.13841	1.12425	1.11828	1.11480	1.11217	1.10996	1.10828	1.10643
30	1.10465	1.10295	1.10124	1.09952	1.09791	1.09629	1.09468	1.09306	1.09145	1.08983
40	1.08821	1.08659	1.08497	1.08334	1.08171	1.08008	1.07844	1.07681	1.07517	1.07353
50	1.07188	1.07023	1.06858	1.06693	1.06528	1.06362	1.06196	1.06029	1.05863	1.05696
60	1.05528	1.05360	1.05192	1.05024	1.04856	1.04687	1.04518	1.04349	1.04179	1.04010
320	0.51024	0.50790	0.50556	0.50322	0.50088	0.49854	0.49620	0.49385	0.49151	0.48916
330	0.48681	0.48446	0.48212	0.47977	0.47741	0.47506	0.47271	0.47036	0.46801	0.46565
340	0.46330	0.46095	0.45860	0.45624	0.45389	0.45154	0.44918	0.44683	0.44447	0.44212
350	0.43976	0.43741	0.43505	0.43270	0.43034	0.42799	0.42563	0.42327	0.42092	0.41856
360	0.41620	0.41384	0.41148	0.40913	0.40677	0.40441	0.40205	0.39969	0.39733	0.39497
370	0.39261	0.39025	0.38789	0.38552	0.38316	0.38080	0.37844	0.37607	0.37371	0.37135
380	0.36898	0.36662	0.36425	0.36189	0.35952	0.35715	0.35479	0.35242	0.35005	0.34768
390	0.34532	0.34295	0.34058	0.33821	0.33584	0.33347	0.33109	0.32872	0.32635	0.32398
400	0.32161									

$$V = 1.08008 \text{ V} \quad @45 \text{ K}$$



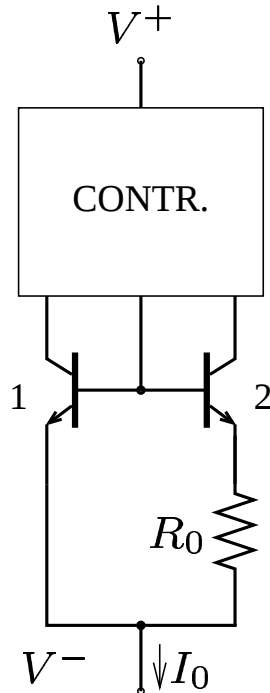
Sensori di temperatura a semiconduttore



- typical response ($\simeq 250$ EUR);
- dispositivi calibrati ($\simeq 1100$ EUR).

Sensori di temperatura a semiconduttore

2 - sensori a circuiti integrati



$$I_{E1} \simeq I_{C1} \simeq \alpha_{F1} I_{ES1} e^{\frac{V_{BE1}}{\eta V_T}}$$

$$I_{E2} \simeq I_{C2} \simeq \alpha_{F2} I_{ES2} e^{\frac{V_{BE2}}{\eta V_T}}$$

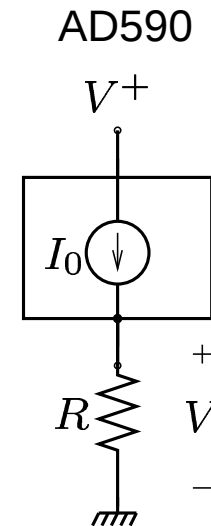
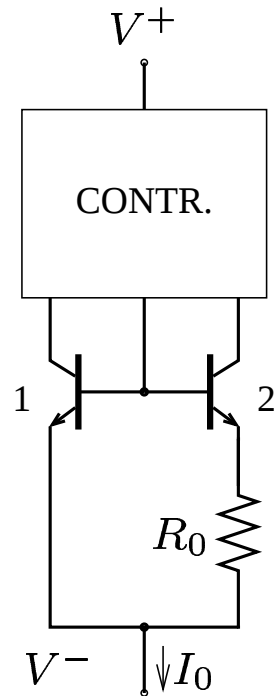
$$\frac{I_{C1}}{I_{C2}} = 1 = H e^{\frac{V_{BE1} - V_{BE2}}{\eta V_T}}$$

$$\log \frac{1}{H} = \frac{V_{BE1} - V_{BE2}}{\eta V_T}$$

Sensori di temperatura a semiconduttore

$$V_{BE1} - V_{BE2} = \eta V_T \log \frac{1}{H} = \eta \frac{kT}{q} \log \frac{1}{H} \rightarrow V_{BE1} - V_{BE2} \propto T$$

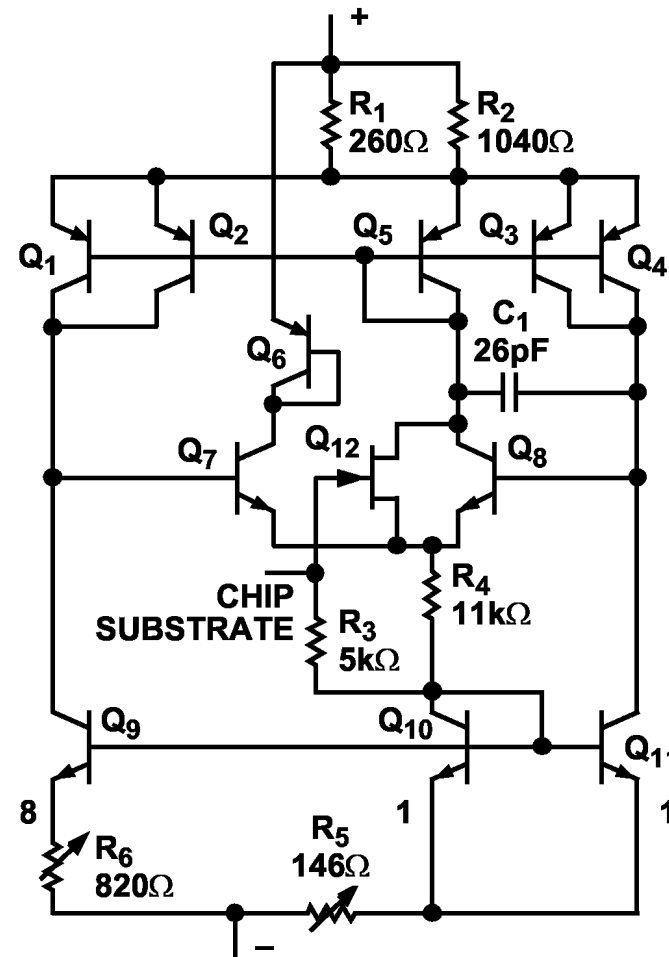
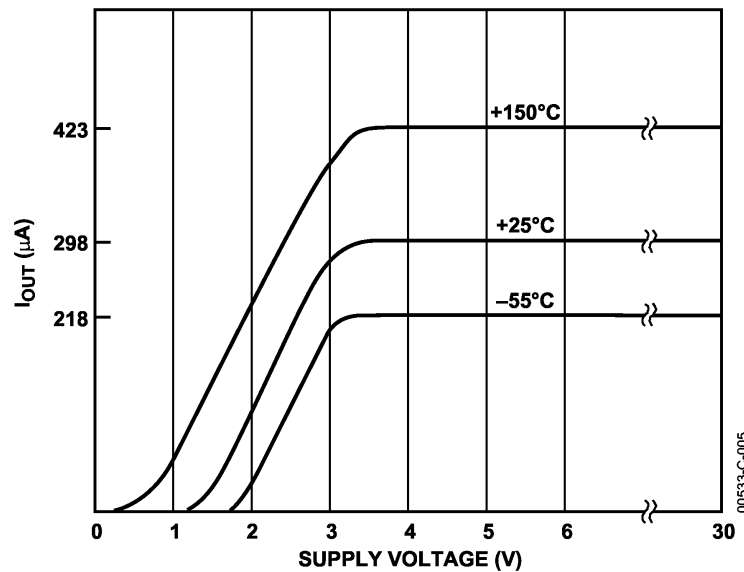
$$V_{BE1} - V_{BE2} \simeq R_0 I_{C2} = 0.5 R_0 (I_{C1} + I_{C2}) = 0.5 R_0 I_0 \propto T$$



Sensori di temperatura a semiconduttore

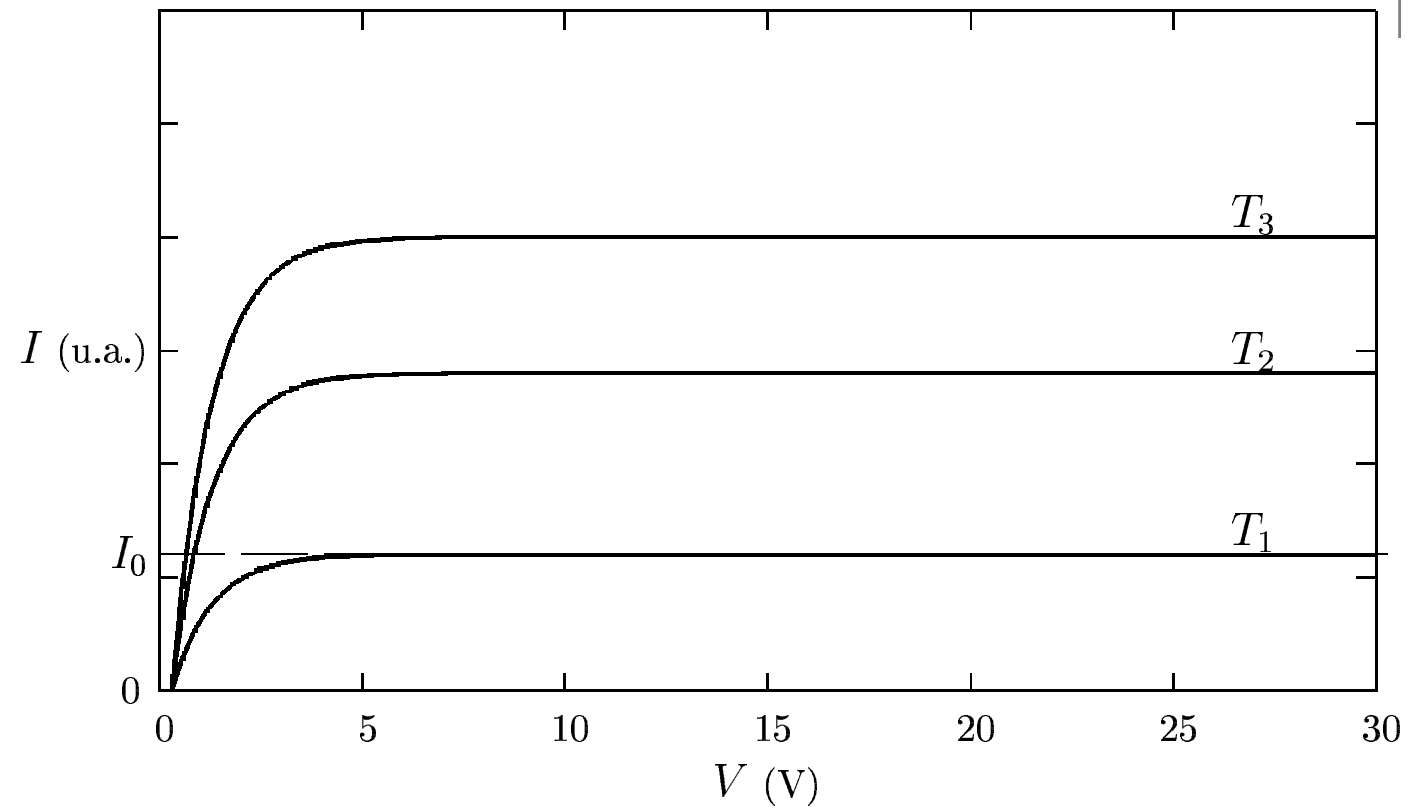
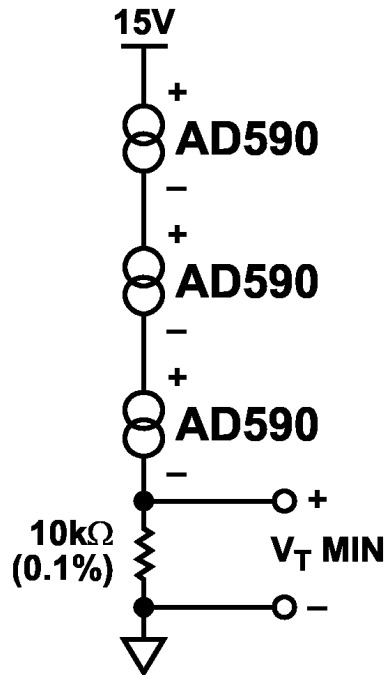
AD590:

- sens.: $1\mu\text{A}/\text{K}$
- $V^+ : 4 \div 30\text{ V}$
- temp. range: $-55 \div 150^\circ\text{C}$



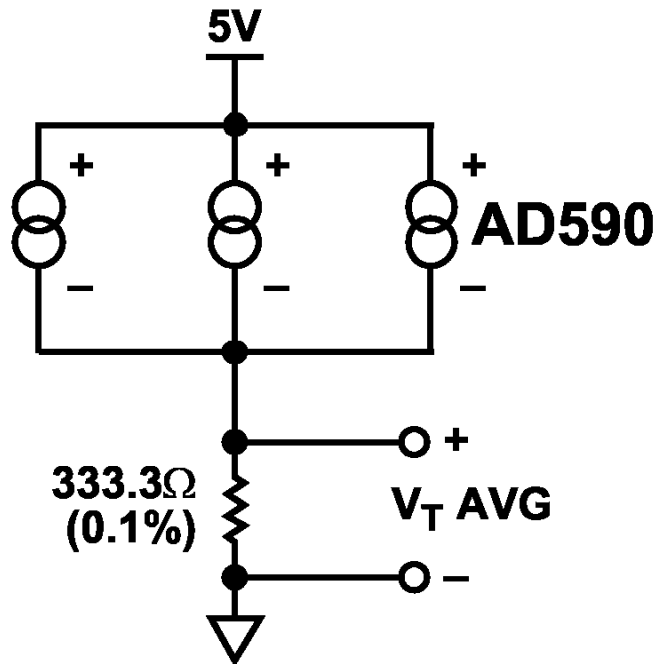
dal sito <http://www.analog.com>

AD590 - esempi di applicazioni (1)



$$V_O \propto \min(T_1, T_2, T_3)$$

AD590 - esempi di applicazioni (2)



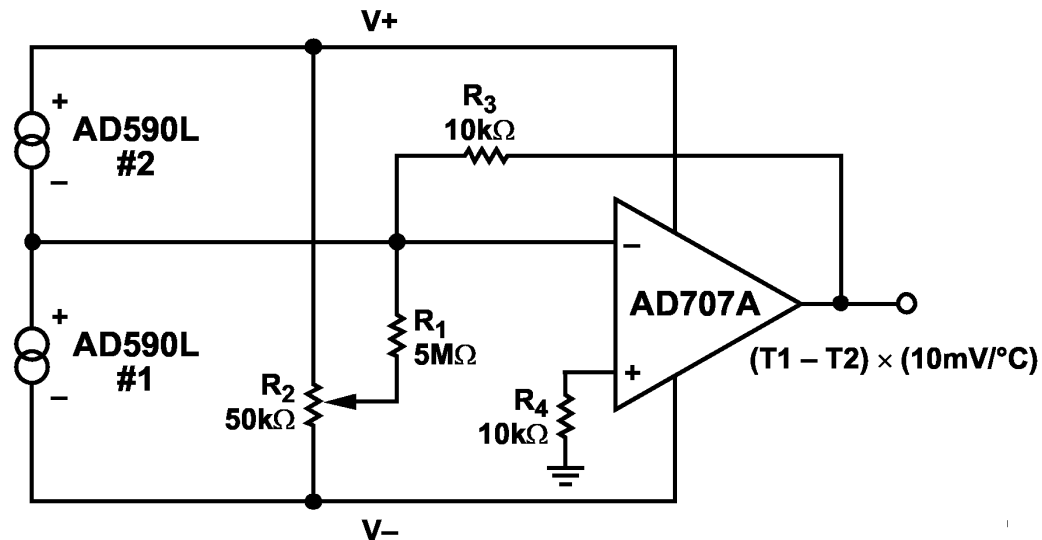
$$V_O = R(I_1 + I_2 + I_3) = kR(T_1 + T_2 + T_3)$$

$$V_O = 3kR \frac{T_1 + T_2 + T_3}{3}$$

$$V_O = k' \frac{T_1 + T_2 + T_3}{3} \quad (k' = 1 \text{ mV/K})$$

$$V_O \propto \text{med}(T_1, T_2, T_3)$$

AD590 - esempi di applicazioni (3)



$$I_n = kT_n$$

$$k = 1 \mu\text{A}/\text{K}$$

$$V_O = -R_3(I_2 - I_1) = kR_3(T_1 - T_2) \quad [= 0 \quad \text{se} \quad T_1 = T_2]$$

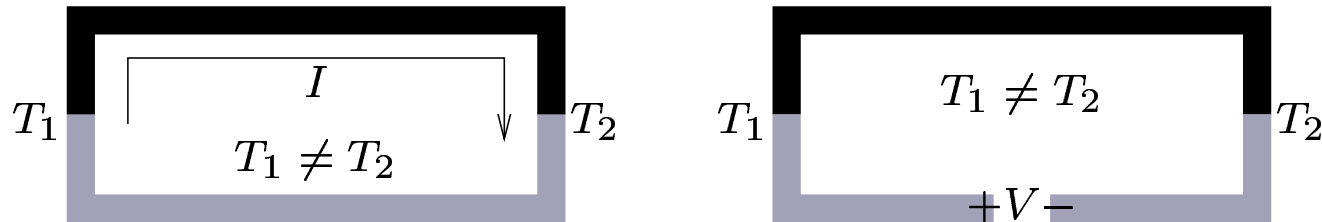
$$V_O = -R_3(I_2 - I_1 + I_{R1}) = kR_3(T_1 - T_2 - T^*), \quad T^* = I_{R1}/k$$

$$[= 0 \quad \text{se} \quad T_1 - T_2 = T^*]$$

dal sito <http://www.analog.com>

Trasduttori termoelettrici

Effetto Seebek: ($\simeq 1820$)



t.	mater.	range ($^{\circ}\text{C}$)	V_{tip}	S
B	Pt/Rh 30% - Pt/Rh 6%	0÷1700	1.24 mV @ 500 $^{\circ}\text{C}$	
E				68 $\mu\text{V/K}$
J				60 $\mu\text{V/K}$
K	NiCr - NiAl (Cromel - Alumel)	-200÷1250	20.64 mV @ 500 $^{\circ}\text{C}$	42 $\mu\text{V/K}$
N				
R	Pt/Rh 13% - Pt	0÷1450	4.47 mV @ 500 $^{\circ}\text{C}$	$\simeq 11 \mu\text{V/K}$
T	Cu - CuNi (Rame - Costantana)	-200÷350	20.9 mV @ 400 $^{\circ}\text{C}$	

tipo	composizione		temperature (°C)
B	Pt-30% Rh	Pt-6% Rh	0 ÷ 1820
E	Ni-Cr	Cu-Ni	-270 ÷ 1000
J	Fe	Cu-Ni	-210 ÷ 1200
K	Ni-Cr	Ni-Al	-270 ÷ 1372
N	Ni-Cr-Si	Ni-Si-Mg	-270 ÷ 1300
R	Pt-13% Rh	Pt	-50 ÷ 1768
S	Pt-10% Rh	Pt	-50 ÷ 1768
T	Cu	Cu-Ni	-270 ÷ 400

B, R, S: metalli nobili.

Termocoppie

$$E = C_1(T_1 - T_2) + C_2(T_1^2 - T_2^2) \quad (+ \dots)$$

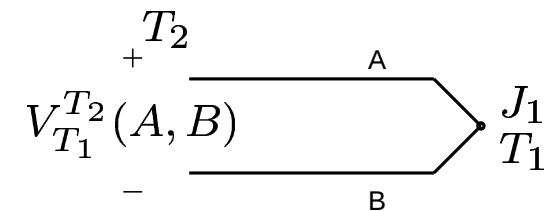
$$E = \sum_{i=1}^n C_i T^i \quad C_i : \text{coeff. Seebeck}$$

$$S = \frac{dV}{dT_2} = -C_1 - 2C_2 T_2 \quad (T_1 = T_{rif})$$

- caratteristica non lineare

→ linearizzazione su range ristretto

→ curva (o tabella) di calibrazione



$$T_{rif} = 273 \text{ K}$$

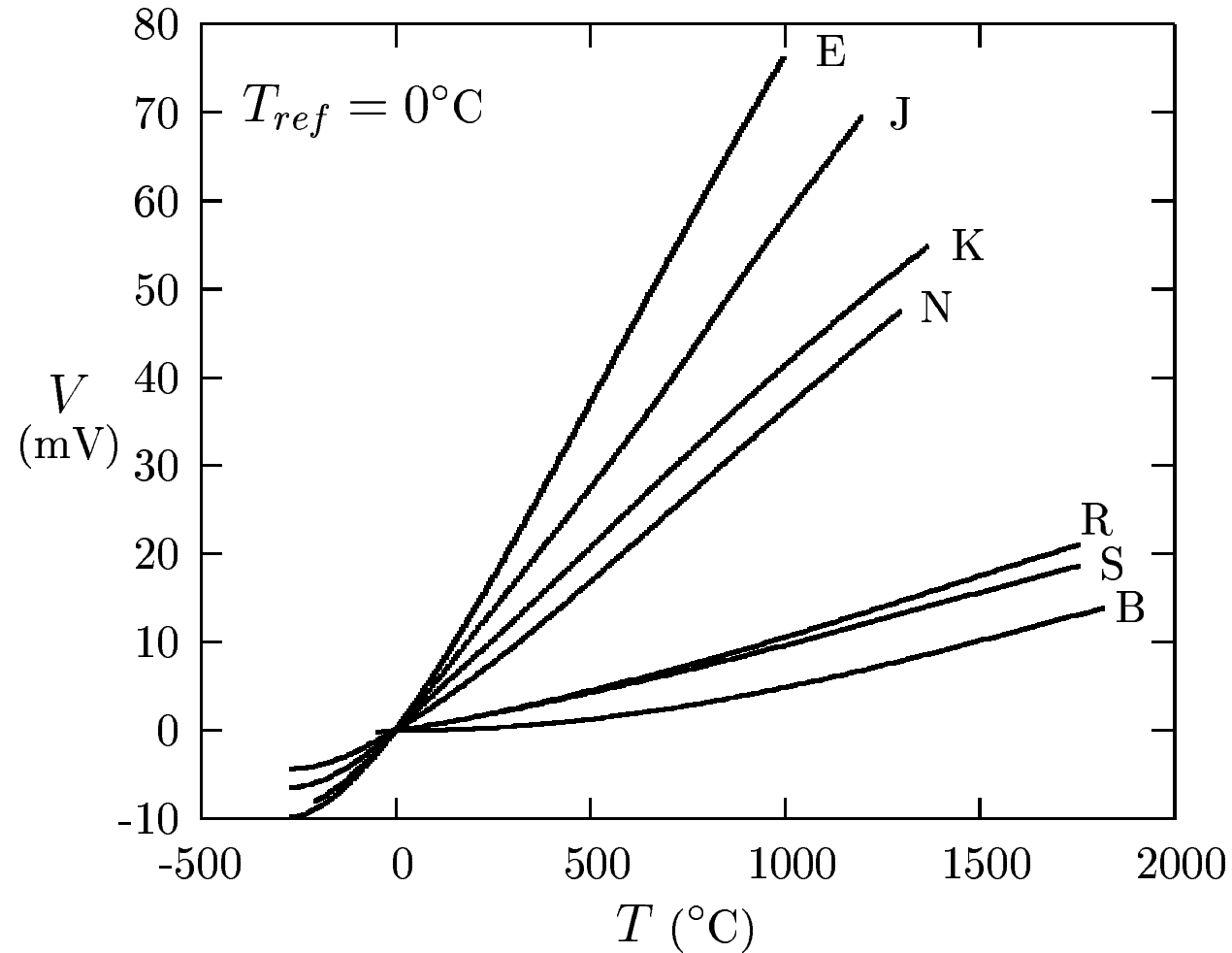
V_A	T_A
V_B	T_B
V_C	T_C
$\dots$	$\dots$

$$V_A < V_X < V_B \quad \rightarrow$$

$$T_X = T_A + (T_B - T_A) \frac{V_X - V_A}{V_B - V_A}$$

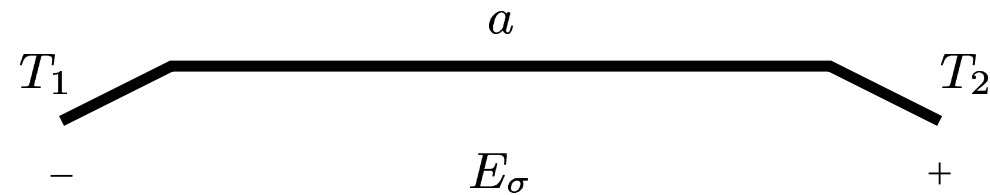
Termocoppie

Caratteristica dipendente dal tipo di termocoppia



fonte: NIST (<http://www.nist.gov>)

Effetto Seebeck - legge fondamentale

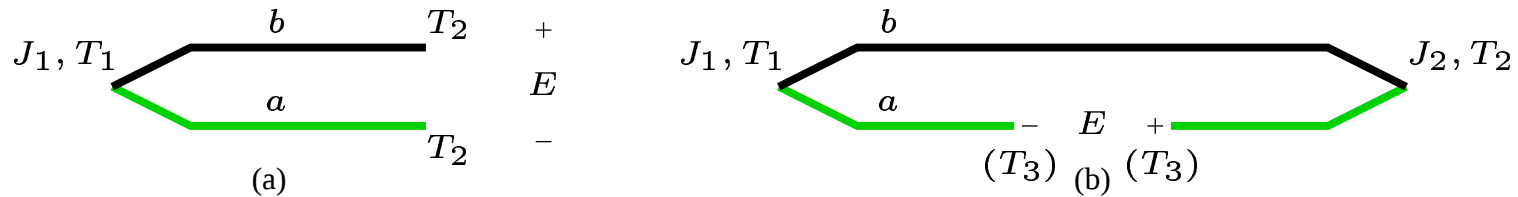


Legge di Seebeck:

$$E_{\sigma} = \int_{T_1}^{T_2} \sigma_a(T) dT = E_a(T_2) - E_a(T_1)$$

- materiale omogeneo: $\frac{d}{dx} \sigma_a(T) = 0$;
- $\sigma_a(T)$ dipendente dal metallo;
- E_{σ} indipendente dall'andamento della temperatura lungo il conduttore.

Termocoppia



$$E_\sigma = \int_{T_2}^{T_1} \sigma_a(T) dT + \int_{T_1}^{T_2} \sigma_b(T) dT = E_a(T_1) - E_a(T_2) + E_b(T_2) - E_b(T_1)$$

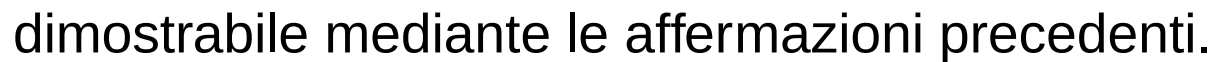
$$E_{T_2}^{T_1}(A, B) \triangleq E_a(T_1) - E_a(T_2) + E_b(T_2) - E_b(T_1)$$

- indifferentemente per (a) o (b)

- indipendenza dalle temperature intermedie

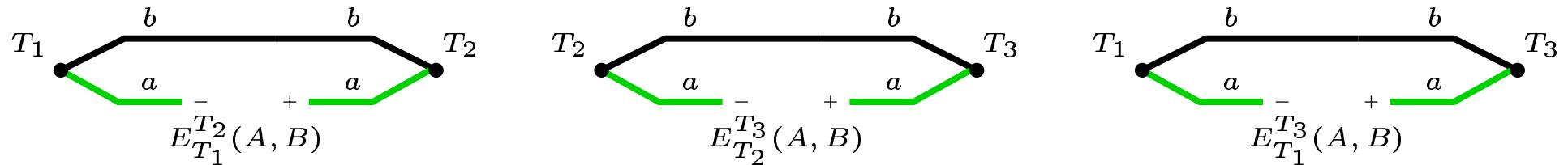
-
- Figure 1 consists of two diagrams, (a) and (b), illustrating the decomposition of a propagator. Diagram (a) shows a propagator with a black upper line and a green lower line. The upper line has a vertex labeled T_3 and is labeled T_2 at its right end. The lower line is labeled T_2 at its right end. The left end of the propagator is labeled J_1, T_1 . The upper line is labeled b and the lower line is labeled a . Diagram (b) shows the same propagator without the vertex T_3 . The diagrams are separated by a plus sign and an equals sign, indicating an identity.

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- Figure 1 consists of two diagrams, (a) and (b), illustrating the decomposition of a propagator. Diagram (a) shows a vertex labeled J_1, T_1 on the left. From this vertex, two lines extend to the right: a black line labeled b and a green line labeled a . Both lines end at a vertex labeled T_2 . Diagram (b) shows the same vertex J_1, T_1 on the left. From this vertex, two lines extend to the right: a black line labeled b and a green line labeled a . These lines end at a vertex labeled T_2 . From this vertex, two red lines extend to the right, both labeled c , and end at a vertex labeled (T) . The diagrams are separated by a plus sign and an equals sign, indicating an identity.



Termocoppie - leggi (2)

- legge della temperatura intermedia

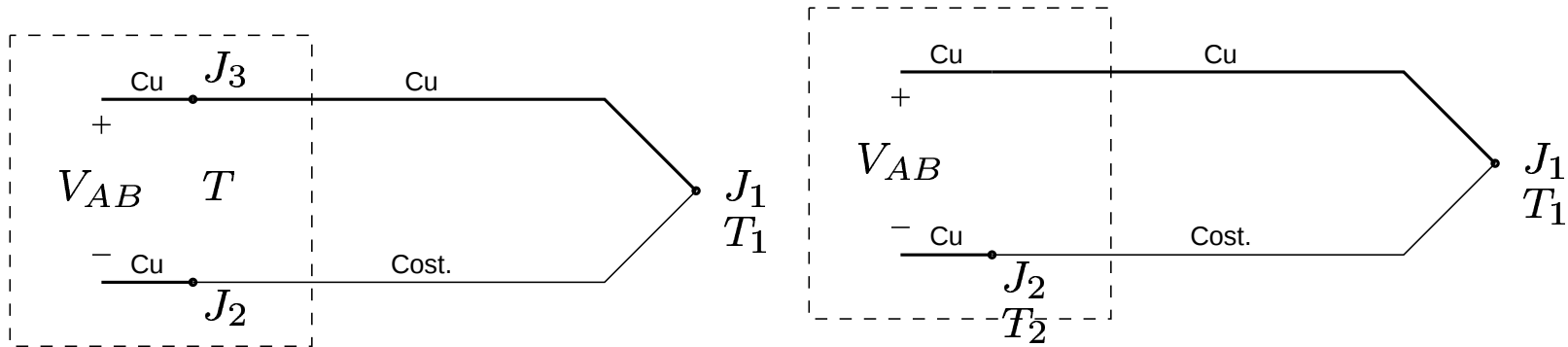


$$E_{T_1}^{T_3}(A, B) = E_{T_1}^{T_2}(A, B) + E_{T_2}^{T_3}(A, B)$$

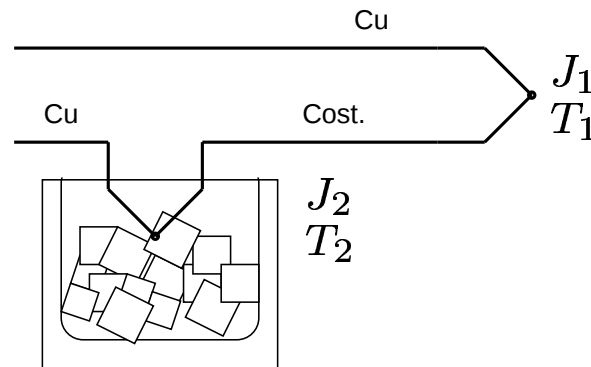
- dimostrabile mediante le affermazioni precedenti
- permette di lavorare con la giunzione fredda a temperatura qualsiasi, purché nota (compensazione)

Termocoppie - misura

a) $B \neq A = \text{Cu}$

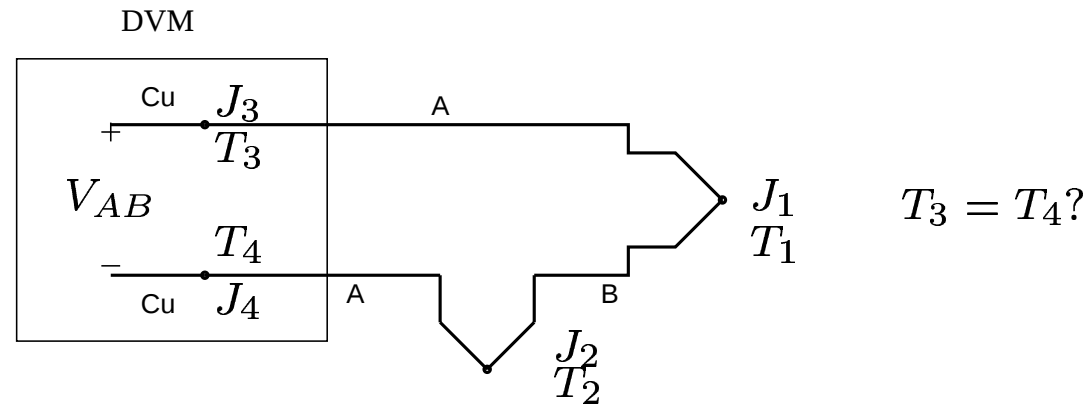


T_2 deve essere nota $\rightarrow$ bagno termostatico



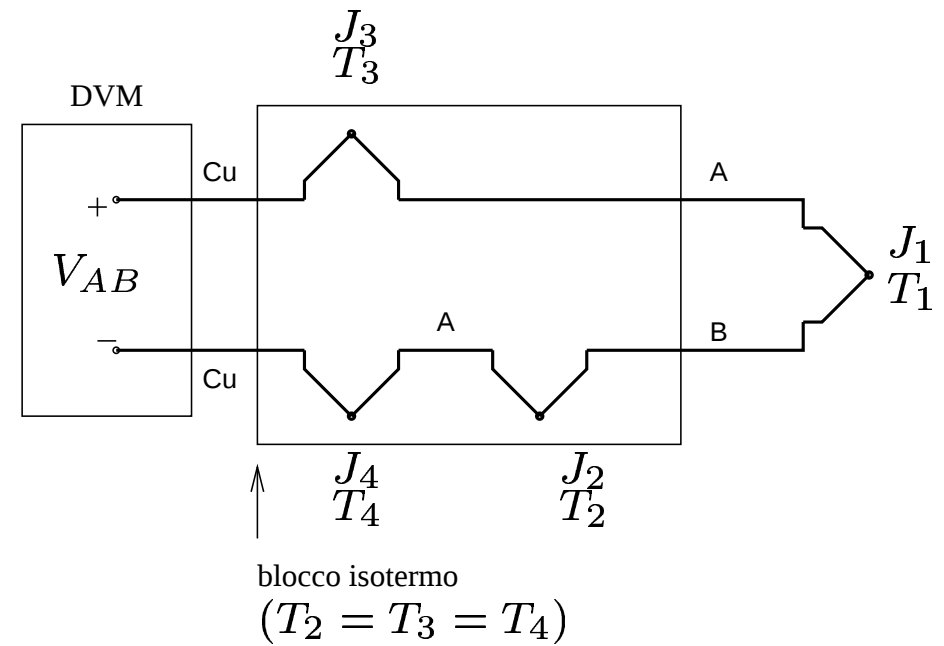
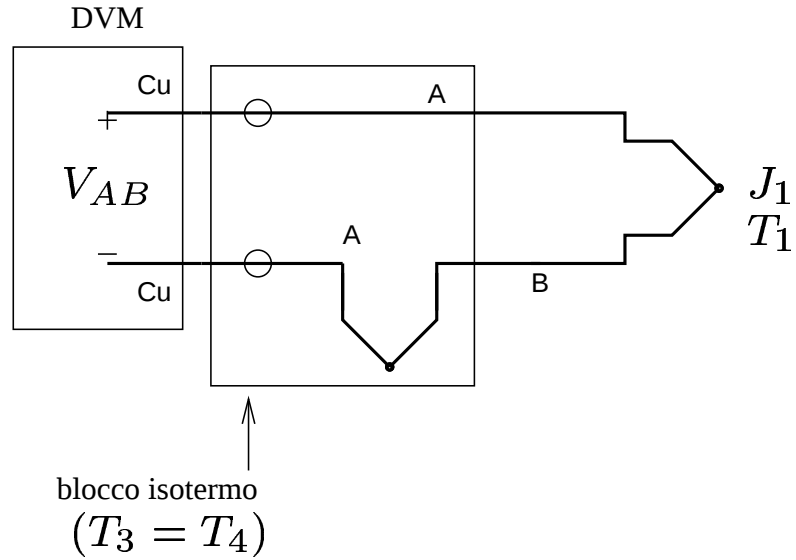
Termocoppie - misura

b) $A \neq B \neq \text{Cu}$



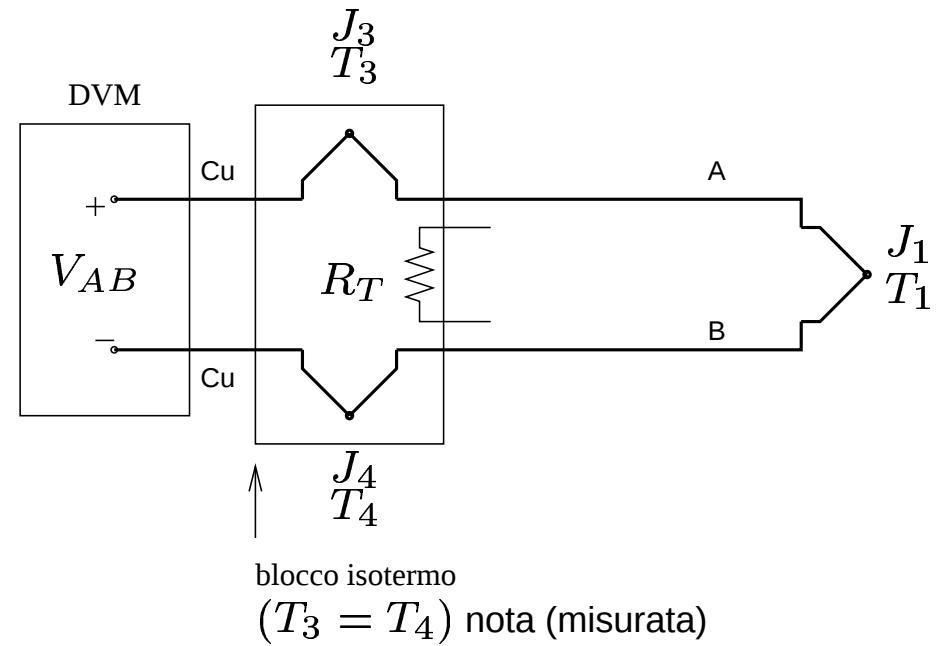
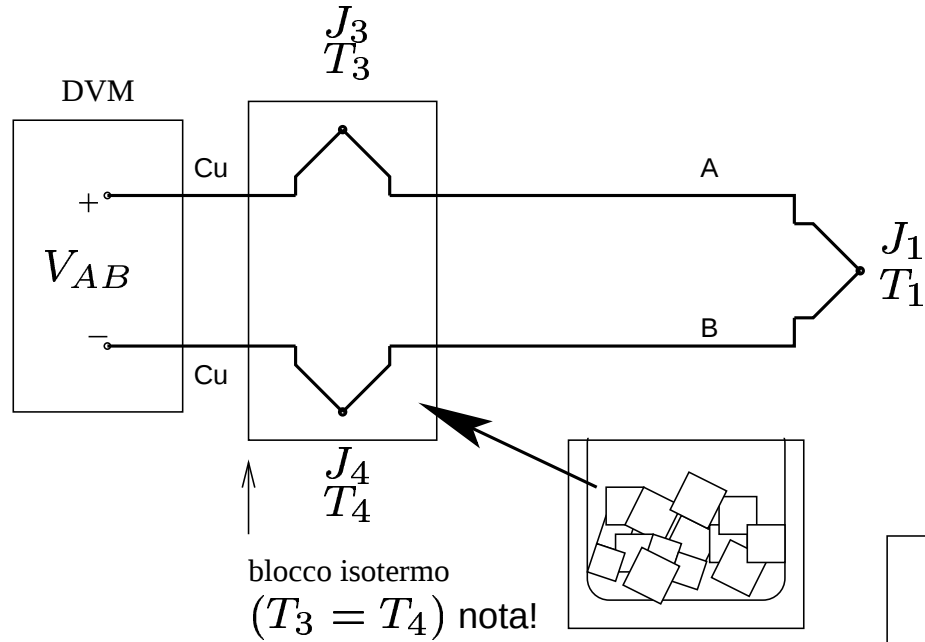
Termocoppie - misura

b) $A \neq B \neq \text{Cu}$ (cont.)



Termocoppie - misura

b) $A \neq B \neq \text{Cu}$ (cont.)



Termocoppie

Realizzazione:

- fili saldati alle estremità
- deposizione dei metalli su substrato

Altre caratteristiche:

- intervallo di misura: $-100^{\circ}\text{C} \div 2300^{\circ}\text{C}$
- dipendenza delle caratteristiche da impurezze (calibrazione)
- necessità di amplificazione della tensione
- necessità di riferimento di temperatura
- discreta robustezza (sonda / termocoppia esposta)

Termocoppie *

- possibilità di impiego in ambienti aggressivi
- possibilità di impiego per alte temperature
- bassa sensibilità a basse temperature
- dimensioni molto ridotte
 - impieghi anche in aghi e cateteri
- tempo di risposta (transistorio termico): $\text{ms} \div \text{s}$ (dipende dalle modalità costruttive, isolamento termico).

Termocoppie



**ITS-90 Table for Type B Thermocouple (Ref Junction 0°C)
Thermoelectric Voltage in mV**

°C	0	1	2		7	8	9	10
100	0.033	0.034	0.035		0.040	0.041	0.042	0.043
110	0.043	0.044	0.045		0.050	0.051	0.052	0.053
120	0.053	0.055	0.056	. . .	0.062	0.063	0.064	0.065
130	0.065	0.066	0.068		0.074	0.075	0.077	0.078
140	0.078	0.079	0.081		0.088	0.089	0.091	0.092

B

dal sito <http://iseinc.com>

Termocoppie

appr. polinomiale: $E = \sum_{i=0}^n c_i T^i$, $[E] = \text{mV}$, $[T] = ^\circ \text{C}$

range: 0.000 ÷ 630.615, n=6

0.00000000000000E+00

-0.246508183460E-03

0.590404211710E-05

-0.132579316360E-08

0.156682919010E-11

-0.169445292400E-14

0.629903470940E-18

range: 630.615 ÷ 1820.000, n=8

-0.389381686210E+01

0.285717474700E-01

...

tipo B, fonte: NIST (<http://www.nist.gov>)

Termocoppie

appr. polinomiale: $T = \sum_{i=0}^n d_i E^i$, $[E] = \text{mV}$, $[T] = ^\circ \text{C}$

Inverse coefficients for type B:

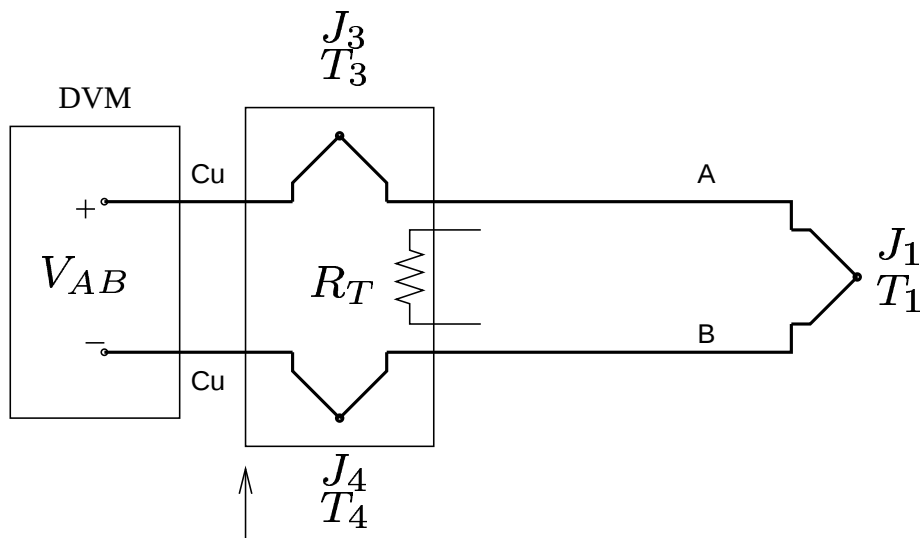
Temperature	250.	700.
Range:	700.	1820.

Voltage	0.291	2.431
Range:	2.431	13.820

9.8423321E+01	2.1315071E+02
6.9971500E+02	2.8510504E+02
-8.4765304E+02	-5.2742887E+01
1.0052644E+03	9.9160804E+00
-8.3345952E+02	-1.2965303E+00
4.5508542E+02	1.1195870E-01
-1.5523037E+02	-6.0625199E-03
2.9886750E+01	1.8661696E-04
-2.4742860E+00	-2.4878585E-06

fonte: NIST (<http://www.nist.gov>)

Termocoppie - misure



blocco isoterma
($T_3 = T_4$) nota (misurata)

Effetti della terza temperatura:

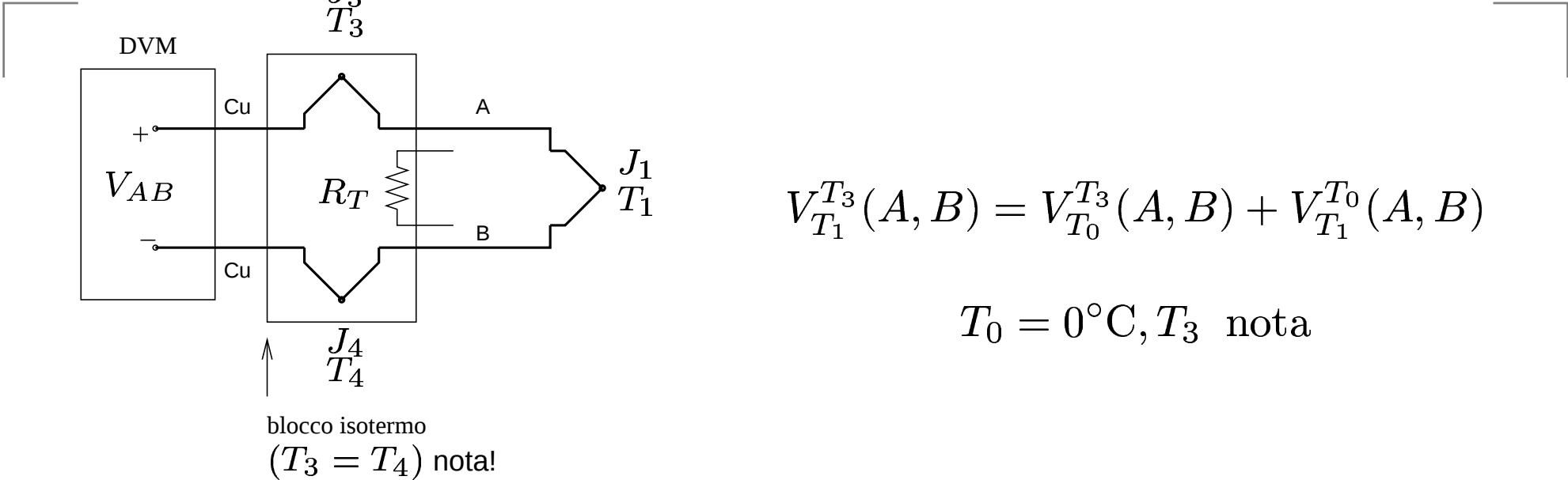
$$V_{AB} = V_{T_1}^{T_3}(A, B)$$

(l. del metallo intermedio)

$$V_{T_1}^{T_3}(A, B) = V_{T_0}^{T_3}(A, B) + V_{T_1}^{T_0}(A, B)$$

T_0 qualsiasi

The diagram shows a horizontal laser beam path. On the left, a box labeled 'DVM' is connected to the beam line. Further right, a box labeled 'T3' is also connected to the beam line. The beam continues to the right, ending at a vertical line representing a detector or screen.



$$V_{AB}^{T_1} = V_{AB}^{T_0} + V_{AB}^{T_1} \quad \text{where} \quad V_{AB}^{T_1} = V_{T_1}^{T_3}(A, B) + V_{T_1}^{T_0}(A, B)$$

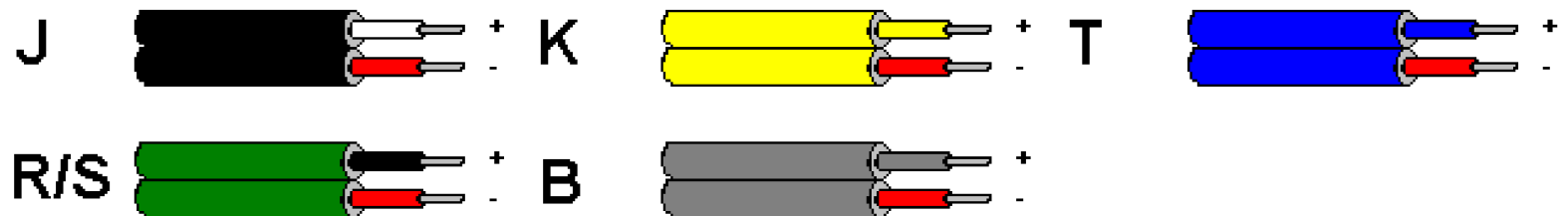
$$T_0 = 0^\circ\text{C}, T_3 \text{ nota}$$

- misura di V_{AB}
- misura di T_3
- determinazione di $V_{T_0}^{T_3}(A, B)$ (da tabelle)
- calcolo di $V_{T_1}^{T_0}(A, B)$ (differenza, compensazione)
- determinazione di T_1 (da tabelle)

Termocoppie

codice a colori:

United States ASTM:



German DIN:

